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The First Stable 9-Silaanthracene

Nobuhiro Takeda, Akihiro Shinohara, and Norihiro Tokitoh*

Institute for Chemical Research, Kyoto University, Gokasho, Uji, Kyoto 611-0011, Japan

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Summary: The first stable 9-silaanthracene, 5, bearing an efficient steric protection group, 2,4,6-tris[bis(trimethylsilyl)methyl]phenyl (Tbt), was successfully synthesized by the reaction of the corresponding silyl triflate, 7, with a 1.0 M amount of lithium diisopropylamide. The aromaticity of 5 is discussed on the basis of the NMR, UV/vis, and Raman spectra, X-ray structural analysis, and theoretical calculations.

Aromatic compounds such as benzene, naphthalene, and anthracene play very important roles in organic chemistry. In recent decades, much attention has been paid to silaaromatics, i.e., $[4n+2]\pi$ electron ring systems containing at least one silicon atom as a ring member.¹ Since silaaromatic compounds are highly reactive and undergo ready dimerization and polymerization, there are few reports on the synthesis and isolation of silaaromatic compounds stable at room temperature. Recently, however, we have succeeded in the synthesis of the first stable 2-silanaphthalene, 1,^{2,3} and silabenzene, 2,^{4,5} by taking advantage of an efficient steric protection group, 2,4,6-tris[bis(trimethylsilyl)methyl]phenyl (denoted as Tbt hereafter).⁶ In contrast, silaanthracenes, silaaromatic species having even more extended $[4n+2]\pi$ electron ring systems than silanaphthalenes, have never been isolated as stable compounds, although there are some reports of the chemical trapping of intermediary silaanthracenes and of observation by UV/vis spectroscopy of unstable silanathracenes in matrixes at low temperature.^{7–9} In this paper, we present the synthesis

Chart 1 SiMe₃ Me₃Si-Th Tbt SiMe₃ Tbt = SiMea Me₃Si 2 1 . SiMe₃

and properties of the first stable 9-silaanthracene bearing a Tbt group.

9,10-Dihydro-9-silaanthracene, 3, bearing a Tbt group on the silicon atom, was prepared by the reaction of TbtSiH₃¹⁰ with bis(2-lithiophenyl)methane generated from bis(2-bromophenyl)methane and butyllithium.⁹ Bromination of **3** with NBS (*N*-bromosuccinic imide) gave the corresponding bromosilane 4, which could in principle be a precursor of 9-silaanthracene, 5. However, attempted dehydrobromination of 4 using LDA (lithium diisopropylamide), *n*-BuLi, or *t*-BuLi was unsuccessful, probably due to the low acidity of the proton at the 10position.¹¹ Treatment of **4** with a "super base", i.e., the 1:1 mixture of *t*-BuLi and *t*-BuOK,¹² and subsequent addition of MeOH resulted in the formation of a small amount of methoxysilane 6 (21%) most likely formed by the reaction of 5 with MeOH. Despite further investigation on the reaction conditions by changing solvents, bases, and reaction temperature, no increase in yield could be achieved. To bring about the ready deprotonation at the 10-position and rapid elimination of the leaving group from the silicon atom, a trifluoromethanesulfonyl group was introduced onto the silicon atom by the reaction of **4** with AgOTf ($Tf = SO_2CF_3$). Optimization of the reaction conditions resulted in almost quantitative formation of 9-silaanthracene, 5, by treatment of silvl triflate 7 with a 1.0 M amount of LDA in benzene at ambient temperature. Since 9-silaanthracene, 5, is scarcely soluble in hexane, 5 was isolated (82%) by filtration of LiOTf from the reaction mixture, followed by the evaporation of the filtrate and the subsequent washing of the residue with dry hexane under argon atmosphere. The formation of 5 was confirmed by NMR, UV/vis, Raman, and high-resolution mass spectroscopy,¹³ and the molecular structure of **5** was determined by X-ray structural analysis.

The ²⁹Si NMR spectrum of **5** in C₆D₆ showed a signal assignable to the silicon atom of the 9-silaanthracene ring at 87.2 ppm, which is very similar to those for 2-silanaphthalene, 1 (87.3 ppm),² and silabenzene, 2

^{*} Corresponding author. Fax: +81-774-38-3209. E-mail: tokitoh@ boc.kuicr.kyoto-u.ac.jp.

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(93.6 ppm).^{4,5} The ²⁹Si NMR chemical shift for 5 in 5:1 THF/C₆D₆, 86.8 ppm, was very little different, suggesting the absence of interaction with THF as a Lewis base. The ¹H and ¹³C NMR spectra indicated that the 9-silaanthracene ring of 5 has a C_2 axis passing through the Si1 and C8 atoms (Table 1), and this result indicates the delocalization of the double bonds in this ring system. The ¹H and ¹³C signals from the 9-silaanthracene ring of 5 were assigned by the 2D NMR technique (Table 1), and all the signals were in the aromatic region. The ¹J_{SiC} value (76 Hz, [D₁₂]cyclohexane) observed for the Si-C bond in the 9-silaanthracene ring of 5 is larger than that of a Si-C single bond (e.g., 50 Hz for Me₄Si)¹⁴ and close to those for 2-silanaphthalene, 1 (92 and 76 Hz, C₆D₆),² and silabenzene, 2 (83 Hz, [D₁₂]cyclohexane).⁴ These results obtained from the ²⁹Si, ¹H, and ¹³C NMR spectra strongly suggest the aromatic character of 9-silaanthracene, 5, as in the case of 2-silanaphthalene, 1² and silabenzene, 2.4,5 Theoretical calculations¹⁵ for the model molecules 9-silaanthracene

Table 1. Observed and Calculated ¹H, ²⁹Si, and ¹³C NMR Chemical Shifts of Silaanthracenes

	5 (obsd)	8 (calcd) ^a	9 (calcd) ^a
H3, H13	8.33	8.00	7.71
H4, H12	7.09	6.86	6.73
H5, H11	7.34	7.30	7.24
H6, H10	7.91	7.74	7.68
H1		6.93	
H8	7.72	7.50	7.43
Si1	87.2	81.5	104.9
C2, C14	128.5	134.8	129.8
C3, C13	133.1	130.2	130.6
C4, C12	118.5	118.1	117.3
C5, C11	127.6	126.8	126.5
C6, C10	131.9	131.5	130.5
C7, C9	142.2	141.6	141.4
C8	116.1	117.1	114.7

a Calculated by GIAO-B3LYP/6-311G(d)(6-311G(3d) for Si)// B3LYP/6-31G(d) level. See ref 16.



Figure 1. ORTEP drawing of 9-silaanthracene, 5, with a thermal ellipsoid plot (50% probability).



(8; R = H) and 9-phenyl-9-silaanthracene (9; R = Ph) were carried out for comparison. The calculated chemical shifts of 8 and 9¹⁶ are in good agreement with the experimental data, suggesting only little perturbation by the Tbt substituent of the 9-silaanthracene system.

The X-ray structural analysis of 9-silaanthracene, 5,17 revealed that the 9-silaanthracene ring is completely planar and the silicon atom at the 9-position has a trigonal planar geometry (Figure 1 and Table 2). The dihedral angle between the 9-silaanthracene ring and

 $[\]begin{array}{c} \hline & (13) \mbox{ Spectral data for 5: mp 178-183 °C (decomp); ^{1}H NMR (400 \mbox{ MHz}, C_6D_6) \delta 0.06 (s, 18H), 0.21 (s, 36H), 1.61 (s, 1H), 2.56 (br s, 1H), 2.66 (br s, 1H), 6.69 (br s, 1H), 6.83 (br s, 1H), 7.09 (ddd, ^{3}J_{HH} = 15.0 \mbox{ Hz}, ^{3}J_{HH} = 8.4 \mbox{ Hz}, ^{4}J_{HH} = 1.2 \mbox{ Hz}, 2H), 7.34 (ddd, ^{3}J_{HH} = 15.0 \mbox{ Hz}, ^{3}J_{HH} = 8.7 \mbox{ Hz}, ^{4}J_{HH} = 1.2 \mbox{ Hz}, 2H), 7.72 (s, 1H), 7.91 (dd, ^{3}J_{HH} = 8.7 \mbox{ Hz}, ^{4}J_{HH} = 1.2 \mbox{ Hz}, 2H), 7.72 (s, 1H), 7.91 (dd, ^{3}J_{HH} = 8.7 \mbox{ Hz}, ^{4}J_{HH} = 1.2 \mbox{ Hz}, 2H), 8.33 (dd, ^{3}J_{HH} = 8.4 \mbox{ Hz}, ^{4}J_{HH} = 1.2 \mbox{ Hz}, 2H); 1^{3} \mbox{ C NMR (100 \mbox{ MHz}, C_6D_6) \delta 1.35 (q), 1.03 (q), 1.163 (q), 118.53 (d), 121.78 (s), 122.41 (d), 127.09 (d), 127.62 (d), 128.50 (s), 131.89 (d), 133.10 (d), 142.18 (s), 148.66 (s), 153.94 (s); ^{29} \mbox{ Si NMR (60 \mbox{ MHz}, C_6D_6) \delta 2.5, 2.6, 87.2; UV/vis (hexane) $\lambda_{max} 278 ($e 2×10^4), 386 (3×10^3), ad8 (7×10^3), 453 (2×10^3), 474 (3×10^3), and 503 \mbox{ mn} (2×10^3), high-resolution FAB-MS m/z calcd for $C_{40}H_68Si_7 744.3706, found 744.3704. (14) \mbox{ Kall nowski, H-O.; Berger, S.; Braun, S. $Carbon-13 NMR \label{eq:adstar}$

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⁽¹⁵⁾ Calculations were carried out using the Gaussian 98 program. (16) The GIAO-B3LYP calculations were carried out with 6-311G-(3d) for Si and 6-311G(d) for C and H. The geometries of 8 and 9 were optimized at the B3LYP/6-31G(d) level; the phenyl group of 9 was fixed

optimized at the BSL 17/6-31G(0) level, the phenyl group of **9** was fixed perpendicular to the 9-silaanthracene ring. (17) Crystal data of **5**: Formula C₄₀H₆₉Si₇, $M_r = 745.57$, triclinic, space group $P\bar{1}$ (#2), Z = 2, a = 10.954(3) Å, b = 13.3077(18) Å, c =17.683(3) Å, $\alpha = 67.639(6)^{\circ}$, $\beta = 74.220(6)^{\circ}$, $\gamma = 73.797(3)^{\circ}$, V = 2249.0-(7) Å³, $D_{calcd} = 1.101$ g/cm³, $\mu = 2.50$ cm⁻¹, $2\theta_{max} = 54.340^{\circ}$, T = 103 K, R_1 ($I > 2\sigma(I)$) = 0.0498, wR_2 (all data) = 0.1224, GOF = 1.047 for 9750 reflections and 442 parameters. Full details of the crystallographic analysis of 5 are described in the Supporting Information.

 Table 2. Observed and Calculated Bond Lengths

 (Å) of Silaanthracenes

	5 (obsd)	8 (calcd) ^a	9 (calcd) ^{<i>a</i>}
Si1-C2, Si1-C14	1.787(3), 1.784(3)	1.782	1.786
C2-C3, C14-C13	1.419(4), 1.414(4)	1.425	1.427
C2-C7, C14-C9	1.442(4), 1.446(4)	1.449	1.451
C3-C4, C13-C12	1.371(4), 1.377(4)	1.371	1.373
C4-C5, C12-C11	1.401(4), 1.417(5)	1.421	1.422
C5-C6, C11-C10	1.345(5), 1.334(5)	1.368	1.370
C6-C7, C10-C9	1.444(4), 1.437(4)	1.434	1.436
С7-С8, С9-С8	1.398(4), 1.399(4)	1.408	1.409

^a Calculated by B3LYP/6-31G(d) level.

the benzene ring of the Tbt group is about 70°. The two Si–C bond lengths in the 9-silaanthracene ring (1.787-(3) and 1.784(3) Å) are almost the same and lie between the typical Si–C double and single bond lengths (1.70 and 1.89 Å, respectively).¹⁸ As for the C–C bond lengths of the 9-silaanthracene ring (1.33–1.45 Å), considerable bond localization was observed for the fused benzene rings as well as the parent anthracene.¹⁹ These experimental values strongly support the conjugation of the π -electrons in the 9-silaanthracene ring of **5**. The calculated bond lengths for the model molecules **8** and **9** are shown in Table 2,¹⁵ and they showed an excellent agreement with the observed values of **5**. This indicates that the Tbt group substituted on the silicon atom little affects the bond lengths of the 9-silaanthracene ring.

The UV/vis spectrum of **5** [$\lambda_{max} = 278$ ($\epsilon 2 \times 10^4$), 386 (3×10^3), 408 (7×10^3), 453 (2×10^3), 474 (3×10^3), and 503 nm (2×10^3)] shows a pattern very similar to that of anthracene, although the λ_{max} values are redshifted compared to those for anthracene.²⁰ The absorption maxima are almost the same as those of 9-silaan-thracene, 9-phenyl-9-silaanthracene, and 9,10-diphenyl-9-silaanthracene, which have been observed under argon matrixes at 15 K by Maier et al.⁷

The Raman spectrum of **5** exhibited the most intense line at 1359 cm⁻¹, while the most intense line for anthracene was observed at 1401 cm⁻¹.²¹ The vibrational frequency of the strongest line observed for **5** is in good agreement with those obtained by theoretical calculation (1338 cm⁻¹, calculated at the B3LYP/6-31G-(d) level and scaled by 0.96).^{15,22}

Although 9-silaanthracene, **5**, is thermally stable even at 100 °C in solution, treatment of **5** with H₂O at room temperature resulted in the ready formation of silanol **10** (90%) via the 1,4-addition of water to the 9- and 10positions. Furthermore, 9-silaanthracene, **5**, reacted with styrene and benzophenone at room temperature to give the corresponding [2+4] cycloadduct, **11** (93%) and **12** (81%), respectively.²³ It was revealed that **5** showed high reactivity toward various reagents despite its aromaticity as well as in the case of 2-silanaphthalene (**1**)² and silabenzene (**2**).^{4,5} The occurrence of the addition to the 9- and 10-positions suggests the conjugation of π -electrons in this ring system.

In summary, we have succeeded in the synthesis of the first stable 9-silaanthracene, **5**, by taking advantage of kinetic stabilization afforded by an extremely bulky substituent, Tbt. The detailed analysis of the spectral data and the X-ray structural analysis revealed that 9-silaanthracene, **5**, is an aromatic compound despite its high reactivity. Further investigation on the 9-silaanthracene, **5**, is currently in progress.

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Supporting Information Available: Text giving experimental procedures and characterization data for the reported new compounds and X-ray structural report of **5**. This material is available free of charge via the Internet at http://pubs.acs.org.

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